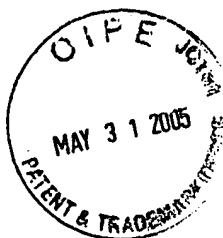


RFW



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Application of:

Shiu-Ko Jangjian

Group Art Unit: 2822

Serial No.: 10/729,217

Examiner: Roy K. Potter

Filed: Dec. 4, 2003

In Response to Office Action
Dated: May 4, 2005

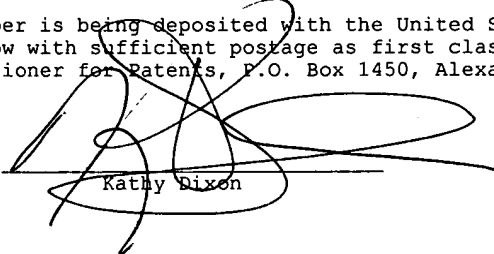
For: Carbon and halogen Doped Silicate Glass Dielectric Layer
and Method for Fabricating the Same

Attorney Docket No.: 67,200-1096

Certificate of Mailing

I hereby certify that this paper is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Date: May 26, 2005


Kathy Dixon

RESPONSE TO OFFICE ACTION

Commissioner for Patents
Alexandria, VA 22313-1450

Dear Sir:

In response to an Office Action mailed May 4, 2005 of a restriction requirement imposed by the Examiner, the Applicants hereby elect with traverse the prosecution of Group I, method claims 1-18.